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TITLE: FORMING METHOD OF PHOTORESISTIVE RESIN WINDOW

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INVENTOR-INFORMATION:

NAME

SUGAWA, TOSHIO

KONUMA, TAKESHI

NAGAMURA, KAZUYO

ASSIGNEE-INFORMATION:

NAME	COUNTRY
MATSUSHITA ELECTRIC IND CO LTD	N/A

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ABSTRACT:

PURPOSE: To make the opening of the first layer larger than that of the second layer after developing treatment in the first layer and the second layer by substantially changing the photosensitive regions of the first layer and the second layer to the photosensitive resin of two layers or more.

CONSTITUTION: Multilayer films 5, 6 consisting of the photosensitive resin films of at least two layers are formed onto a substrate 4, and the condition of etching of the films 5, 6 are made differ. Accordingly, the opening section of the film 5 contacting with the substrate 4 is shaped so as to be contained in the opening section of the film 6. The conditions of etching are made differ in response to the sensitivity of the films 5, 6, the difference of irradiated beams to the films 5, 6, etc.

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